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On-chip Dynamic Mode Atomic Force Microscopy: A silicon-on-insulator MEMS approach

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Abstract—The atomic force microscope (AFM) is an invaluable scientific tool, however its conventional implementation as a relatively costly macroscale system is a barrier to its more widespread use. A microelectromechanical systems (MEMS) approach to AFM design has the potential to significantly reduce the cost and complexity of the AFM, expanding its utility beyond current applications. This paper presents an on-chip AFM based on a silicon-on-insulator MEMS fabrication process. The device features integrated xy electrostatic actuators and electrothermal sensors as well as an AlN piezoelectric layer for out-of-plane actuation and integrated deflection sensing of a microcantilever. The 3-degree-of-freedom design allows the probe scanner to obtain topographic tapping-mode AFM images with an imaging range of up to $8 \mu m \times 8 \mu m$ in closed loop.

Index Terms—Atomic force microscope, piezoelectric self-sensing, electrothermal sensing, electrostatic actuation, microelectromechanical systems (MEMS)

I. INTRODUCTION

FOR several decades, the atomic force microscope (AFM) has remained one of the primary instruments used for nanoscale object and material analysis in both research and industrial applications. At the heart of the AFM is a microcantilever with a sharp probe tip, which is scanned over the surface of a sample. By mapping the intermolecular forces that exist between the probe tip and the surface of the sample, the instrument is able to obtain the sample’s topography and material properties with nanometer-scale resolution.

Since its introduction in the late 1980s [1], the AFM has generally been implemented as a macroscale system, with the instrument itself being many orders of magnitude larger than the size of the scan window. Conventionally, the in-plane scanning of the microcantilever is performed using piezoelectric tube scanners or flexure-guided nanopositioners, while the deflection of the microcantilever is measured using a laser and a position sensitive detector [2], [3]. While commercial AFMs are often able to perform high-speed scanning with sub-nanometer resolution, their high cost of acquisition and the relative size of the hardware setup generally restricts their use to specialized laboratory-based applications.

More recently, microelectromechanical systems (MEMS)-based devices have emerged as a means of generating mechanical displacements with nanoscale precision in a much smaller form factor than that of conventional macroscale nanopositioners [4]–[6]. In addition, a MEMS implementation provides several other significant advantages, including much lower costs of fabrication, batch manufacturability, and potentially increased operating bandwidths [7], [8]. Given these potential benefits, we have previously explored the use of MEMS nanopositioners for AFM through the demonstration of silicon-on-insulator (SOI)-based devices as an AFM’s scanning stage [9]–[12]. In [13], an in-plane MEMS nanopositioner with two degrees of freedom (DOF) was presented, which features electrostatic actuators and electrothermal sensors. The first resonance mode of the device along each axis is located at approximately 850 Hz, which enabled imaging in closed loop using a raster scan method with a maximum frequency of 100 Hz. However, the relatively low bandwidth of the device limits the maximum achievable imaging frequency. As such, a high-bandwidth 2-DOF MEMS nanopositioner was presented in [14] with more than 4.4 kHz bandwidth along each axis. AFM imaging of the device was performed using the raster scan method at 800 Hz in a window size of $8 \mu m \times 8 \mu m$.

Non-raster trajectories such as Lissajous and spiral methods were also implemented for a novel MEMS nanopositioner in [10] and [15] respectively to achieve fast in-plane scans. Using these methods, much higher scan frequencies of 1000 Hz for the Lissajous method and 1430 Hz for spiral scanning were demonstrated.

Having successfully miniaturized one of the primary subsystems of the AFM, the next logical step is the development of a complete MEMS-based AFM. It is possible that the significant cost and portability improvements that may be achieved with the introduction of such a device may allow the AFM to move beyond its current role as a specialized scientific instrument.

In the literature, a single-chip AFM has been demonstrated that uses a CMOS-MEMS fabrication process [16], [17]. While the device has undergone a number of design iterations, it maintains the use of lateral and vertical electrothermal actuators to position a cantilever. The device is designed to operate in tapping mode, with the amplitude of the resonantly excited cantilever’s oscillation being measured through the use of piezoresistive sensing. The authors have successfully used the device to obtain topographical images of various samples, demonstrating the feasibility of a microfabricated AFM. However, the use of electrothermal actuation mechanisms potentially places a number of limitations on the performance of the
device. Specifically, the operating bandwidth of electrothermal actuators is limited by their thermal mass and their rate of heat dissipation, therefore restricting the ultimate scan rate achievable by the AFM [18], [19]. In addition, electrothermal actuators use significantly more electrical power than other forms of MEMS actuators [20]. While power consumption may not be a major consideration for a standalone device, it may become an issue if attempts are made to increase the effective scan throughput by implementing multiple devices within an array.

Integrated cantilever actuation and sensing are paramount as the traditionally employed piezo stack actuator at the base of the cantilever and the optical beam deflection (OBD) method [21] are not compatible with the idea of a single-chip AFM. Furthermore, some of the integrated actuation methods found in the literature such as magnetic [22], photothermal [23], or ultrasonic [24] still require external equipment. As such, resistive thermal actuation [25] or via a piezoelectric layer [26] and integrated sensing methodologies such as capacitive [27], piezoresistive [28], and piezoelectric [29] sensing are fully compatible with an on-chip solution. Among these methods, piezoelectric transduction seems to be the only one capable of simultaneously serving as an actuator and a sensor even with a single active layer [30] which was therefore chosen for this work.

In [31], we introduced a microfabricated probe scanner, which demonstrated a novel SOI-MEMS approach to designing an on-chip AFM. The device used electrostatic comb-finger actuators to laterally position a stage containing an integrated silicon cantilever. Using a dedicated piezoelectric actuator, the cantilever was driven at its out-of-plane vibrational mode at 62 kHz, however no AFM images were able to be obtained with the device as it did not possess a probe tip.

This paper presents a redesigned MEMS probe scanner that is again fabricated using a SOI-MEMS fabrication process. The device features a central stage that is positioned along the x and y axes using electrostatic actuators, with integrated electrothermal displacement sensors being implemented to facilitate closed-loop position control of the stage. A silicon microcantilever designed for tapping-mode AFM is fabricated at one end of the stage, and is actuated in the out-of-plane direction using a piezoelectric transducer made from a thin layer of aluminum nitride (AlN). Using a high-side charge sensing implementation motivated by previous work [32], the same piezoelectric transducer is also used to simultaneously measure the deflection of the cantilever. Following the addition of a probe tip to the end of the cantilever, the probe scanner is successfully used to perform AFM scans of features on a calibration grating.

II. PROBE SCANNER DESIGN AND FABRICATION

A. Mechanical Design

A scanning electron microscope (SEM) image of the MEMS probe scanner is shown in Fig. 1. The probe scanner is implemented using the standard SOI-based PiezoMUMPs fabrication process provided by MEMSCAP [33]. The thickness of the device layer, from which the entire structure is obtained, is 10 µm.

At the center of the device is a stage with dimensions of 2315 µm × 650 µm, while a two-section microcantilever...
is fabricated at the upper edge of the stage. The in-plane displacement of the stage is obtained using a parallel kinematic mechanism. Along the device’s x axis, electrostatic actuators are implemented on both sides of the stage, enabling it to have a bidirectional displacement range. An electrostatic actuator is also implemented on one side of the stage along the y axis, resulting in unidirectional displacement in this direction. As is visible in the close-up view in Fig. 1, the actuators are connected to the stage via shuttle beams and tethering beams in both directions. Two sets of electrostatic actuators are implemented along the x axis to obtain higher force while mitigating potential in-plane rotation of the stage.

As the y axis has a relatively large unidirectional displacement range, using standard clamped-clamped beams as mechanical flexures can lead to the stage possessing a nonlinear force-displacement behavior. In [12], folded beam flexures are proposed that provide in-plane stiffness with negligible nonlinearity compared to clamped-clamped beams. We have exploited this characteristic by designing the y-axis flexures in a similar manner. As the stage has a bidirectional displacement range along the x axis, clamped-clamped beams can be used in this direction as their stiffness can be considered to be linear within the displacement range of interest. In addition, these beams have a smaller form factor compared to the folded flexures, leading to a more compact structure in this direction. The incorporated mechanical suspension systems in both axes are designed to prevent the occurrence of snap-in within the electrostatic actuators by providing sufficient longitudinal stiffness throughout the entire range of displacement and actuation voltages [11].

The implemented microcantilever has two sections, with the wider section having dimensions of 380 µm × 240 µm and the narrower part being 260 µm × 40 µm. In order to oscillate the cantilever and simultaneously measure its vibration amplitude, an AlN piezoelectric layer with a thickness of 0.5 µm is deposited on the wider section of the microcantilever. The signal routing for the piezoelectric layer and the electrical ground connections to the stage is performed using long beams with dimensions of 2.3 mm × 25 µm and 2.3 mm × 10 µm, respectively. The width of these beams are minimized while considering the restrictions imposed by the microfabrication process. Serpentine structures are also implemented at the anchor points of these beams to reduce their in-plane stiffness along the y direction.

During the design, the finite element model (FEM) of the probe scanner is constructed in CoventorWare to investigate its mechanical characteristics. The results of the FEM modal analysis are presented in Fig. 2. The device is designed such that its first two in-plane resonant modes are along the x and y axis as shown in Fig. 2(a) and (b), respectively. A resonance frequency of about 2.9 kHz is predicted for both axes, matching well with the experimental results shown in Fig. 4. In Fig. 2(c), a high-frequency (172 kHz) mode shape of the device is shown, which, due to its large displacement and negligible induced motion in the rest of the device, is designed to be suitable for tapping-mode AFM imaging (compare experimental results in Section III and Fig. 5).

Electrothermal sensors are implemented for both axes to measure the in-plane motion of the stage. As is shown in a close-up view in Fig. 1, the sensor comprises two heaters in proximity to a heat sink, which is implemented as a part of each shuttle beam [34]. As the heat sink moves parallel to the heaters, the rate of heat transfer between the heaters and the heat sink changes. This leads to opposing variations in their temperature, and as a result, changes in the electrical resistance of the heaters. A transimpedance circuit (shown in more detail in [14]) is used to translate the electrical resistance changes of the heaters to a varying output voltage.

### B. AFM Tip

A sharp tip was added to the fabricated probe scanner using a focused ion beam (FIB) system (FEI Nova NanoLab 200), allowing the device to be used to image a sample via tapping-mode AFM. This method of AFM tip fabrication has been utilized in both commercial cantilever production and research applications, and is capable of producing high-resolution, high-aspect-ratio tips [35]. Using ion beam deposition of platinum, a stepped support structure with a total height of approximately 9 µm was first constructed at the end of the probe scanner’s cantilever. A thin platinum needle was then deposited at the top of the support structure using electron beam deposition, yielding a tip 1.5 µm in length and with a diameter of approximately 40 nm. SEM images of the deposited probe tip are shown in Fig. 1.
While the use of an FIB system for tip fabrication is sufficient to demonstrate the operation of the probe scanner, a MEMS microfabricated tip is ultimately required to enable the cost-effective batch fabrication of the device. This is possible through techniques such as KOH wet etching or isotropic reactive ion etching [36], [37], which are currently being evaluated to enable the complete batch fabrication of future versions of the probe scanner.

III. XY-NANOPositioner CHARACTERIZATION AND CONTROL

The characterization of the fabricated system is performed while the electrothermal sensors are active with a 5 V bias voltage. As the electrostatic actuators along the x axis are implemented on both sides of the stage, a linear actuation mechanism can be implemented for this axis [14]. With this mechanism, the actuation signal is applied to the electrostatic actuators with opposite polarities while superimposed on a DC bias voltage, which is adjusted to be 35 V in our experiments. This mechanism can drastically alleviate the well-understood quadratic behavior of the electrostatic actuators [14].

The in-plane mechanism of the device is characterized in both the time and frequency domains. A low frequency triangular signal is applied to both axes, while their displacements are measured using a Polytec MSA-100-3D Micro System Analyzer (MSA). In Fig. 3, the in-plane displacement for both axes is shown as a function of the actuation signal. The displacement along the x axis slightly deviates from linear as shown in Fig. 3a. This can be attributed to nonlinearities in the stiffness of the clamped-clamped beams and possible asymmetry in the structure of the comb drive actuators. The quadratic behavior of the y axis is also visible in Fig. 3b. A displacement range of more than 10 µm is obtained for both axes. The outputs of the electrothermal sensors are simultaneously recorded and are presented in the same figure for both axes. Each sensor’s output is a linear function of the corresponding axis displacement, with the resulting calibration factors for the sensors being reported in Table I.

TABLE I

<table>
<thead>
<tr>
<th></th>
<th>x axis (V/µm)</th>
<th>y axis (V/µm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Calibration factor (V/µm)</td>
<td>0.468</td>
<td>0.285</td>
</tr>
<tr>
<td>1σ-Resolution (nm)</td>
<td>5.2</td>
<td>7.6</td>
</tr>
</tbody>
</table>

The frequency response of the in-plane mechanical structure is obtained for both axes using the MSA, and is shown in Fig. 4. As is visible, the first resonant modes along the x and y axes are located at 2.85 kHz and 2.77 kHz, respectively.

The out-of-plane vibration of the microcantilever is also characterized in the frequency domain by applying a wide-band periodic chirp as an actuation signal to its piezoelectric transducer. During this test, the MSA is used to obtain the various out-of-plane mode shapes of the probe scanner by measuring the mechanical response of the device at a large number of points across its moving structure. The objective is to determine a mode shape within which the cantilever has a large enough oscillation amplitude to be used for tapping-
mode AFM imaging while other parts of the device show negligible displacement. The experimental test shows that this criteria is best satisfied at the mode located at approximately 200 kHz, with Fig. 5 showing the vibration of the probe scanner at this mode.

To obtain the resolution of the electrothermal sensors, their output noise is characterized in the time-domain. The noise is recorded with a sampling frequency of 781 kHz over a time period of 12.8 s. A fourth-order anti-aliasing low-pass filter with a cut-off frequency of 100 kHz is employed by series connecting two Stanford Research SR560 low-noise voltage preamplifiers. The resolution of the sensors is reported in Table I, and is calculated by converting the root mean square (rms) value of the sensors’ output noise to the corresponding displacement using their previously obtained calibration factors.

IV. CANTILEVER CHARACTERIZATION AND CONTROL

A. System Model

Assuming perfect bonding between the piezoelectric transducer and the cantilever beam and a clamped boundary condition at the base of the cantilever, a voltage applied to the electrodes results in a bending moment causing the cantilever to deflect. The transfer function from actuation voltage \( V(s) \) to tip displacement \( D(s) \) of the piezoelectric cantilever, can be described by a sum of \( n \) second order modes \([38]\)

\[
G_{dc}(s) = \frac{D(s)}{V(s)} = \sum_{i=1}^{n} \frac{\alpha_i \omega_i^2}{s^2 + \frac{\omega_i^2}{Q_i} s + \omega_i^2},
\]

(1)

where each second order term is associated with a specific vibrational mode shape and is characterized in terms of the respective resonance frequency \( \omega_i \), quality factor \( Q_i \), and gain \( \alpha_i \). Similarly, when the piezoelectric transducer is subjected to mechanical strain, it becomes electrically polarized, producing a charge on the surface of the material. Neglecting parasitic effects, this direct piezoelectric effect can be modeled as a strain dependent voltage source \( V_p(s) \) in series with the piezoelectric capacitance \( C_p \), describing the dielectric properties of the material \([30]\). The model is a simplified version of the Butterworth Van Dyke model as proposed by the IEEE Standard on Piezoelectricity \([39]\). For this simplified case, the transfer function from actuation voltage to charge \( Q(s) \) can be found to be \([40]\)

\[
G_{qv}(s) = \frac{Q(s)}{V(s)} = C_p + C_p \sum_{i=1}^{n} G_{vv,i}(s)
\]

(2)

where

\[
G_{vv}(s) = \frac{V_p(s)}{V(s)} = \sum_{i=1}^{n} \frac{\beta_i \omega_i^2}{s^2 + \frac{\omega_i^2}{Q_i} s + \omega_i^2}
\]

(3)

is the transfer function from actuation voltage to piezoelectric strain voltage \([41]\). Observing that each mode in \( G_{dc} \) and \( G_{vv} \) only differ by a constant factor, (2) can be rewritten to yield

\[
G_{qv}(s) = \frac{Q(s)}{V(s)} = C_p + C_p \sum_{i=1}^{n} \gamma_i G_{dv,i}(s).
\]

(4)

Fig. 6. (a) Electrical circuit model of the piezoelectric cantilever impedance with series parasitic resistance due to the silicon ground trace. (b) Frequency response of the complex impedance of the piezoelectric cantilever measured with an impedance analyzer (–) and model (5) (–).

B. Piezoelectric Impedance

For this work, the above equivalent model is not sufficient to describe the electrical properties of the MEMS probe scanner. As such, it had to be amended by an additional parallel resistance \( R_p \) to take into account dielectric losses as well as a series resistance \( R_s \) which models the parasitic arising from the doped silicon ground trace. The equivalent electrical model of the piezoelectric layer is shown in the circuit diagram in Fig. 6(a). The resulting impedance \( Z(s) \) can be calculated as

\[
Z(s) = R_p |\frac{C_p + R_s}{R_p C_p R_s + R_p + R_s}|
\]

(5)

To validate the model, the complex impedance \(|Z|\) in \( \text{dB} \), \( \angle Z \) in deg) is measured with an impedance analyzer (Keysight, 4990A) and plotted in Fig. 6(b) and compared with the model (5). It can be seen that the extra zero caused by the series resistance \( R_s \) adequately describes the phase increase in the frequency range from 10 kHz to 1 MHz. The parallel resistance \( R_p \) creates a pole at low frequencies and does not contribute significantly to the behavior of \( Z(s) \). Solving for the individual terms of the model (5) based on the identified model of the impedance transfer function shown in Fig. 6(b) yields the values shown in Table II.

C. Frequency Response

The frequency response of the piezoelectric cantilever from actuation voltage to tip deflection as measured with the optical

---

TABLE II

<table>
<thead>
<tr>
<th>( C_p ) (pF)</th>
<th>( R_p ) (MΩ)</th>
<th>( R_s ) (Ω)</th>
</tr>
</thead>
<tbody>
<tr>
<td>237</td>
<td>3.12</td>
<td>318</td>
</tr>
</tbody>
</table>

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From (4) it can be seen that a deflection estimate can be obtained by measuring the charge on the piezoelectric layer while the cantilever is being actively driven by a voltage source if the feedthrough \( C_p V(s) \) can be canceled.
Fig. 7. Frequency response of the probe scanner piezoelectric cantilever measured with the OBD sensor (−) and its identified model (1) (−) highlighting the first four dominant flexural modes.

<table>
<thead>
<tr>
<th>Table III</th>
<th>Cantilever Model Parameters</th>
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<tbody>
<tr>
<td>Mode</td>
<td>$f_i$ (kHz)</td>
</tr>
<tr>
<td>M1</td>
<td>69.4</td>
</tr>
<tr>
<td>M2</td>
<td>107.4</td>
</tr>
<tr>
<td>M3</td>
<td>156.0</td>
</tr>
<tr>
<td>M4</td>
<td>198.3</td>
</tr>
</tbody>
</table>

beam deflection sensor of a commercial AFM (AFMWorkshop, TT-AFM) is shown in Fig. 7. Plotted alongside, is the identified transfer function model according to (1) capturing 16 modes, including the four dominant out-of-plane flexural modes as highlighted in the figure. The frequency response highlights the collocated nature of the eigenmodes of the probe scanner. Here, we chose the eigenmode M4 as the imaging mode for the reasons discussed in Section III.

D. Thermal Stiffness

A thermal noise spectrum was obtained by recording time-domain deflection data in free-air using the MSA sampled at 3.125 MHz for 8 s. From the measurement, the velocity power spectral density (PSD) estimate is calculated using Welch’s method with 16 averages without overlap. The resulting PSD estimates for each of the four eigenmodes, highlighted in Fig. 7, are shown in Fig. 8 together with the Lorentzian function fits to determine modal resonance frequencies, Q-factors, and stiffnesses. The identified parameters are summarized in Table III.

E. Piezoelectric Sensor Design

In order to measure the cantilever deflection using the piezoelectric transducer while simultaneously using the same layer for actuation, a self-sensing configuration is necessary. In previous works, the self-sensing interface with a piezoelectric cantilever was achieved using a low-side charge amplifier circuit situated at the opposite electrode of the piezoelectric layer with respect to the actuation signal [30]. While good results have been achieved with this configuration, in this work a different approach had to be taken due to the fact that the piezoelectric layer shares a common node with the rest of the electrical network of the MEMS device. In other words, the grounded electrode of the piezoelectric layer is not accessible. Therefore, an approach similar to the reciprocal self-sensing arrangement [32] had to be employed and is subsequently termed high-side charge sensing. A simplified circuit diagram is shown in Fig. 9. Here, the driving op-amp maintains the input signal $V_{in}(s)$ across the piezoelectric layer and the charge generated by the strain dependent voltage source $V_p(s)$ is measured on a reference capacitor $C_f$ on the same side as the actuation signal (therefore high-side charge sensor). To measure the charge on the reference capacitor,
an instrumentation amplifier or a difference amplifier with a high-impedance buffer amplifier (on the node connected to the piezoelectric layer) should be employed. The transfer function of the sensor can be derived as follows (for the sake of simplicity the series resistance $R_s$ is neglected in this analysis but will be taken into account for feedthrough cancellation in the next subsection). The voltage across a resistor and across a capacitor can be written as a function of charge as $V_r = sQR$ and $V_c = Q/C$. Thus, we can write for loop A

$$Q(s) = \frac{C_f R_f s + 1}{C_f R_f s} Q_{cf}(s)$$  \hspace{1cm} (6)

and for loop B

$$Q(s) = \frac{C_p R_p s + 1}{R_p} V_{in}(s) + C_p V_p(s).$$  \hspace{1cm} (7)

Equating (6) and (7) and solving for the voltage $V_{cf}$ yields

$$V_{out}(s) = \frac{R_f C_p R_p s + 1}{R_p C_f R_f s + 1} V_{in}(s) + \frac{C_p R_f s}{C_f R_f s + 1} V_p(s)$$

$$= H(s) V_{in}(s) + F(s) V_p(s).$$  \hspace{1cm} (8)

Fig. 10. (a) Block diagram showing the schematic setup of charge measurement and feedthrough cancellation. (b) Simulated single-mode transfer function $G_{zh}(s)$ (.—), sensor model (8) (.—) and $F(s)$ (.—) and recovered deflection estimate $F(s)V_p(s)$ (.—).

It can be noticed that the transfer function (8) contains a feedthrough term $H(s)V_{in}(s)$ and that the motional term is filtered by a term $F(s)$. To develop a better understanding of the sensor behaviour, a simulation of the relevant transfer functions is shown in Fig. 10(b). It can be clearly observed how the feedthrough term heavily swallows the dynamics of the resonance. Moreover, it is noticeable that the feedthrough transfer function $H(s)$ and the motional filter $F(s)$ have the same pole which needs to be placed lower than the resonance frequency. This requirement dictates the choice of the sense impedance $R_f||C_f$ while keeping in mind that the high-frequency gain of the sensor is $C_p/C_f$ and the low-frequency gain is $R_f/R_p$. At this point, a high piezo impedance $R_f||C_f$ is beneficial for the sensor design as it implies that the zero created by the piezo impedance is much smaller than the pole due to the sense impedance. At the frequencies of interest, the resulting piezo impedance is quite low causing the zero to be placed at approximately 6.7 kHz. Therefore, the sense impedance is chosen to be $C_f = 47\,\text{pF}$, $R_f = 250\,\text{k\Omega}$ resulting in a pole at approximately 13.5 kHz.

In order to recover the motional signal from the sensor output, the feedthrough term $H(s)V_{in}(s)$ has to be canceled from the sensor signal in real-time. This can be done with a feedforward compensator $K(s)$ as schematically depicted in Fig. 10(a). Theoretically, the feedforward compensator is a first order lead lag element but due to the extra dynamics in the piezoelectric impedance associated with parasitic resistance in the MEMS device, a second order transfer function is

Fig. 11. Top: Frequency response of charge sensor (.—) and fitted feedthrough compensator (second order bandpass filter) (.—). Bottom: Offline feedthrough cancellation using the exact model (.—) and an approximate model based on the realizable FPAA implementation (.—).

Fig. 12. Frequency response of the M4 mode of the probe scanner piezoelectric cantilever measured with the TT-AFM OBD sensor (.—), with the charge sensor before feedthrough cancellation (.—) (the inset shows a zoomed view of the resonance) and after feedthrough cancellation (.—). Magnitude and phase plots have been shifted such that the difference in dynamics is clearly visible.
be seen in Fig. 12, around the mode of interest (M4 at 200 kHz) on the FPAA based on the design discussed above. As can the simulated cancellation as shown in Fig. 11. Clearly, the major resonances M1-M4 are visible, however unusable unless the feedthrough is removed. With the identified second order model of the feedthrough part, all the resonances can simultaneously be recovered offline as shown in Fig. 11. However, as the feedthrough cancellation is implemented on a Field Programmable Analog Array (FPAA) (Anadigm, AN221E04) additional constraints on the realizable second order filter limit the bandwidth in which the feedthrough can be accurately removed. Therefore, the filter has to be specifically tuned to a single mode which results in the simulated cancellation as shown in Fig. 11.

A second order biquadratic filter has been implemented on the FPAA based on the design discussed above. As can be seen in Fig. 12, around the mode of interest (M4 at \( f \approx 200 \text{kHz} \)), the mechanical resonance is recovered from the feedthrough resulting in a dynamic range of around 19 dB compared to a dynamic range of around 0.03 dB for the uncompensated frequency response (compare inset). In the vicinity of the resonance, the well matching phase and magnitude response with the frequency response taken with the OBD sensor indicates that the charge sensor output is purely related to the mechanical movement. Away from the resonance, it can be observed how the higher order nature of the feedthrough component results in a deviation from the estimated. The measured charge sensor frequency response is shown in Fig. 11. However, as the feedthrough cancellation is implemented on a Field Programmable Analog Array (FPAA) (Anadigm, AN221E04) additional constraints on the realizable second order filter limit the bandwidth in which the feedthrough can be accurately removed. Therefore, the filter has to be specifically tuned to a single mode which results in the simulated cancellation as shown in Fig. 11.

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C. AFM Imaging

A number of AFM images have been obtained, starting with a small scan range image of $4 \mu m \times 4 \mu m$ with the xy actuators in open loop up to a scan range of $8 \mu m \times 8 \mu m$ with integral control on the xy actuators to eliminate actuator nonlinearity. No image processing has been applied to the results; topography images have been plane corrected. Initially, the cantilever deflection was measured with the AFM-inherent OBD sensor and with the charge sensor in parallel, however ultimately the charge sensor was used to provide the feedback signal for topography imaging. It can be seen in the results shown in Fig. 15 that the OBD and charge sensor estimates show an equal amplitude error image, and that due to the open loop in the x and y directions some scanning nonlinearities are visible. These nonlinearities are largely eliminated by closing the loop in the x and y directions as can be seen in the results shown in Fig. 16 where the topography images are obtained with the charge sensor providing the z axis feedback signal. At the bottom of the features, it can be seen how the deteriorated state of the tip has led to a triangular artifact as compared to Fig. 15(a).

VI. Conclusion

We have presented an on-chip atomic force microscope for tapping-mode AFM imaging based on a silicon-on-insulator MEMS fabrication process. The device is equipped with electrostatic actuators that provide a maximum travel range of $10 \mu m$ along the x and y directions. For these axes, electrothermal sensors are employed to control any tracking errors arising from drift and nonlinearities with digitally implemented integral control. In the z direction, a single piezoelectric (AlN) actuator is used to actuate the cantilever at one of its resonance frequencies and a high-side charge sensor is used to recover the deflection signal from the piezoelectric signal. This is possible with a model-based feedthrough cancellation scheme implemented on an FPAA. The device was equipped with a post-fabricated FIB tip and thereafter successfully used to image a calibration grating. Future work will focus on improving the piezoelectric impedance properties over frequency and possibly separate actuation and sensing such that feedthrough cancellation can be avoided. The authors are currently working on a revised design incorporating the tip fabrication step into the device fabrication.

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REFERENCES

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